### Accepted Manuscript

Title: An innovative method for the microstructural modification of TiAl alloy solidified via direct electric current application

Authors: Zhanxing Chen, Hongsheng Ding, Ruirun Chen, Shiqiu Liu, Jingjie Guo, Hengzhi Fu

PII: DOI: Reference: S1005-0302(18)30189-0 https://doi.org/10.1016/j.jmst.2018.06.016 JMST 1299

To appear in:

 Received date:
 14-1-2018

 Revised date:
 12-6-2018

 Accepted date:
 27-6-2018

Please cite this article as: Chen Z, Ding H, Chen R, Liu S, Guo J, Hengzhi F, An innovative method for the microstructural modification of TiAl alloy solidified via direct electric current application, *Journal of Materials Science and amp; Technology* (2018), https://doi.org/10.1016/j.jmst.2018.06.016

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.



### ACCEPTED MANUSCRIPT

# An innovative method for the microstructural modification of TiAl alloy solidified via direct electric current application

Zhanxing Chen, Hongsheng Ding\*, Ruirun Chen, Shiqiu Liu, Jingjie Guo, Hengzhi Fu

National Key Laboratory for Precision Hot Processing of Metals, School of Materials Science and Engineering, Harbin Institute of Technology, Harbin, 150001, China

\*Corresponding author, Prof., PhD; Tel:+86 451 86412394; Fax: +86 45186415776; E-mail address:dhs801@163.com (H.S. Ding)

#### [Received 14 January 2018; Received in revised form 12 June 2018; Accepted 27 June 2018]

#### Abstract:

Ti-48Al-2Cr-2Nb alloy solidified with the application of direct electric current has a refined and homogeneous microstructure without segregation. We observed an initial decrease followed by a subsequent increase in grain size and lamellar spacing, with the increase in current density. Similar trend can also be obtained by varying the amount of  $\alpha_2$ -phase (Ti<sub>3</sub>Al). Using a directional solidification processing method, the columnar crystal microstructure transforms into an equiaxed crystal microstructure at a current density of 32~64 mA/mm<sup>2</sup>. High dislocation density is also introduced with a minimum cross-sectional grain size of 460 µm at a current density of 64 mA/mm<sup>2</sup>. The application of electric current alters the free energy of the critical nucleus and temperature via joule heating, causing a transformation from a columnar grain microstructure into into an equiaxed grain microstructure. The increase in current density leads to a rise of the nucleation rate, and a resulting undercooling combined with temperature gradient contribute to growth of the primary phase, which finally results in grain coarsening at a critical current density of 96 mA/mm<sup>2</sup>. The climb and cross-slip of dislocation and the migration of grain boundary Download English Version:

## https://daneshyari.com/en/article/10155785

Download Persian Version:

https://daneshyari.com/article/10155785

Daneshyari.com